Electronic Patent Application Fee Transmittal							
Application Number:	10792038						
Filing Date:	03-Mar-2004						
Title of Invention:	Composition and process for post-etch removal of photoresist and/or sacrificial anti-reflective material deposited on a substrate						
First Named Inventor/Applicant Name:	Melissa K. Rath						
Filer:	Tristan Anne Fuierer						
Attorney Docket Number:	ATMI-668						
Filed as Large Entity							
Utility Filing Fees							
Description		Fee Code	Quantity	Amount	Sub-Total in USD(\$)		
Basic Filing:							
Pages:							
Claims:							
Miscellaneous-Filing:							
Petition:							
Patent-Appeals-and-Interference:							
Post-Allowance-and-Post-Issuance:							
Extension-of-Time:							
Extension - 1 month with \$0 paid		1251	1	120	120		

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
	Total in USD (\$)			120